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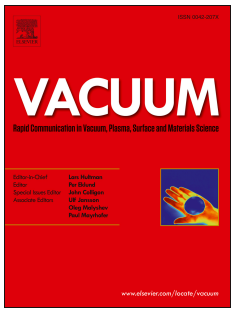

Optimization of self-propagating reaction properties through Al-molar ratios in ternary Titanium-Silicon-Aluminum reactive multilayer films

Seema Sen, Markus Lake, Peter Schaaf

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